

Title (en)  
ELECTRON BEAM CURABLE EPOXY COMPOSITIONS

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Application  
**EP 92902738 A 19911122**

Priority  
US 63810591 A 19910104

Abstract (en)  
[origin: WO9212183A1] Deep section epoxy compositions are cured by irradiation with e-beam, x-ray, or gamma -ray radiation. Use of photoinitiators having metal halide anions makes monomers and oligomers especially susceptible of this invention's deep section curing technology.

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**C08F 2/46**; **C08G 77/14**; **C08J 3/28**

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**C08G 59/306** (2013.01); **C08G 59/3254** (2013.01); **C08G 59/68** (2013.01); **C08L 83/06** (2013.01)

Citation (search report)

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- [X] US 4310469 A 19820112 - CRIVELLO JAMES V
- [X] EP 0389927 A2 19901003 - GEN ELECTRIC [US]
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- [A] DE 3629701 A1 19870305 - CIBA GEIGY AG [CH]
- [A] CRIVELLO J. V., LEE J. L.: "THE SYNTHESIS, CHARACTERIZATION, AND PHOTOINITIATED CATIONIC POLYMERIZATION OF SILICON-CONTAINING EPOXY RESINS.", JOURNAL OF POLYMER SCIENCE, POLYMER CHEMISTRY EDITION., INTERSCIENCE PUBLISHERS, NEW YORK, NY., US, vol. 28., no. 03., 1 February 1990 (1990-02-01), US, pages 479 - 503., XP000141356, ISSN: 0360-6376
- See references of WO 9212183A1

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